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Observation of surface states on heavily indium doped SnTe(111), a superconducting topological crystalline insulator

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The topological crystalline insulator tin telluride is known to host superconductivity when doped with indium (Sn1–xInxTe), and for low indium content (x = 0.04) it is known that the topological surface states are preserved. Here we present the growth, characterization and angle resolved photoemission spectroscopy analysis of samples with much heavier In doping (x > 0.30), a regime where the superconducting temperature is increased nearly fourfold. We demonstrate that despite strong p-type doping, Dirac-like surface states persist.

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I. INTRODUCTION

Three dimensional topological insulators constitute a popular and active topic in contemporary condensed matter physics, primarily stemming from the exotic properties of the surface states in these systems. This set of properties can be enriched even further when combined with superconductivity1–3. Notably, such a system represents a quasiparticle approach to realizing a Majorana fermion. While such a realization is of considerable importance to the particle physics community, the interest also extends further into quantum computation, where Majorana bound states potentially represent a qubit platform.

Accordingly, there is an active branch of research into candidate materials. One approach is to deposit a superconductor on a regular TI, relying on the proximity effect3,4. An alternative is to find bulk-superconducting materials which natively possess topological surface states - examples are Cu12Bi2Se3 (Tc = 3.8K for x = 0.14)5–7 and Sn1−xInxTe8–13. For the latter, an indium content of x = 0.04 yields a critical temperature of 1.2 K and topological surface states appear to persist14. However it has recently been realised that the critical temperature can be increased to 4.5 K with a higher In content of x = 0.4511. An immediate question is whether this increase comes at the cost of the topological surface states. Specifically, while the lower limit of cubic SnTe is a confirmed topological crystalline insulator, the same cannot be said of the lower symmetry upper limit, tetragonal InTe.

Angle-resolved photoemission spectroscopy (ARPES) can play an important role here, but the strong p-type doping in SnTe due to natural Sn vacancies15 makes this challenging. The doping becomes even more severe with the introduction of indium, which acts as a p-type dopant in SnTe8. To date a Dirac point has never been observed in photoemission measurements of pure SnTe, but can nothet be inferred from measurements of heavily lead doped SnTe16,17. Here we report the in-situ growth and photoemission study of (111) oriented Sn1−xInxTe films with high (x > 0.30) indium contents. Despite severe p-type doping, we clearly observe that Dirac-like surface states persist at these high indium contents.

II. METHODS

High quality (111) oriented surfaces of (Sn,In)Te were prepared in ultrahigh vacuum (UHV) by a hot-wall epitaxy method. After ex-situ cleaving shortly before entry into UHV, BaF2 substrates were prepared by being heating to >400°C for several hours. For deposition the substrate temperature was reduced to ≈330°C. Thick films of (Sn,In)Te (≈1.5μm) were deposited by single source open hot-wall epitaxy19, using ex-situ re-crystallized Sn0.6In0.4Te as source material. All subsequent photoemission measurements were performed without removing the samples from UHV (< 2×10−10 Torr). LEED measurements (Figure 1a) confirm that the (Sn,In)Te films grow with a (111) orientation.

All UV photoemission measurements were performed at the I4 beam line at the MAX-IV synchrotron facility18, using p-polarized photons. The total energy resolution (beamline and spectrometer) was configured for 25 meV, except for the higher energy scans in Figures 2 and 5 (≈85 meV). Fermi level positions within the films were determined by reference to a clean tantalum foil on the manipulator. This was found to be accurate to within only ≈30 meV in most cases, presumably owing to charging effects from the BaF2 substrate. For high resolution
valence band spectra, the Fermi level position was revised by careful examination of the intensity distribution in the spectra.

Owing to its low melting temperature and high vapor pressure relative to Sn, In has a tendency to segregate to the surface during film growth (which we discuss in more detail below). In order to understand the depth-dependent In concentration, complementary hard x-ray photoemission (HAXPES) measurements were also performed on separate thin film samples, as well as on the precursor Sn$_{0.6}$In$_{0.4}$Te single crystals. For these measurements, photon energies of 2.14 keV and 4 keV were used, with energy resolutions of $\approx 180$ meV and $\approx 220$ meV and probing depths of $\approx 3.5$ nm and $\approx 6.5$ nm, respectively (compared with $< 1$ nm at UV energies). The thin film samples used for the HAXPES experiment were grown and characterized in UHV at Beamline X1B of the NSLS using similar parameters to the UV ARPES samples, before being transferred (with exposure to atmosphere) to the HAXPES instrument. The angle-integrated valence band of both bulk single crystal and as-grown thin film were very similar to one another (Figure 1e), and in good agreement with previous measurements of SnTe$^{20}$, confirming that electronically the grown films are In-doped SnTe.

### III. STOICHIOMETRY CHARACTERIZATION

In this article we will mainly discuss two film samples, produced with slightly different source and sample temperatures and thus with different stoichiometry. Normal emission ultraviolet core level spectroscopy (UPS) (Figure 1b) at photon energies of 70 eV and 94 eV suggests an indium content which is significantly higher than the $x = 0.045$ bulk crystals studied previously$^{14}$. A simplistic quantification based on the ratio of peak areas and photoionization cross sections$^{21}$ suggests surface indium contents of $x = 0.58$ and $x = 0.33$ for the two films. Similar analysis of a uniform $x = 0.40$ bulk crystal at a photon energies of 80 eV yields an indium fraction of $x = 0.56^{22}$, suggesting that in this low energy regime the theoretically calculated cross section ratio should be slightly rescaled. This lowers the estimate for the films to more realistic values of $x = 0.41$ and $x = 0.23$. Scanning the $\approx 100 \mu m \times 25 \mu m$ light spot across the sample showed no obvious variation in the core level ratios.

Supporting measurements of the film stoichiometry are not trivial owing mainly to indium segregation at the surface, i.e. the stoichiometry is strongly depth dependent. This is confirmed by both HAXPES measurements of a separate (but similarly prepared) sample, as well as secondary ion mass spectroscopy (SIMS) of the $x = 0.41$ film. Figure 1c and 1d compares core level spectra of the grown film and the bulk precursor crystal, measured with photon energies of 2.14 keV ($\lambda_{ad} \approx 3.5$ nm) and 4 keV ($\lambda_{ad} \approx 0.5$ nm). Here $\lambda_{ad}$ is the inelastic mean free path of the In/Sn 4d photoelectrons, a measure of the depth sensitivity. For the $x = 0.40$ bulk crystal the core level peak areas are not appreciably different for the two photon energies, consistent with a spatially uniform indium content. The same quantification technique as employed for the UPS spectra yields indium fractions of $x = 0.49$ at 2.14 keV and $x = 0.48$ at 4 keV. In contrast, for the film the indium core level signal is notably reduced at higher photon energies, consistent with a spatially uniform indium content.

For the purposes of interpreting our angle resolved spectra it is only the near-surface stoichiometry that is of principle interest, since the photoelectrons in this case possess very short inelastic mean free paths ($< 1$ nm). Techniques such as energy dispersive x-ray spectroscopy (EDX) with probing depths of several $\mu m$ are therefore not representative. For example, EDX performed on the films grown in this study yielded indium concentrations as low as $x \approx 0.04$, corresponding to the depth-averaged In content and clearly not in agreement with the surface sensitive in-situ UPS measurements. Throughout the manuscript we will continue to label the two Sn$_{1-x}$In$_x$Te...
films by UPS estimated indium contents of $x = 0.41$ and $x = 0.23$, but it should be understood that these values represent only a best estimate. This method of stoichiometry determination can be influenced for example by resonance effects, detector non-linearity or the accuracy of photoionization cross sections.

It is interesting to consider why such a high indium content has apparently been obtained in a single-phase crystal, when previous work has indicated the emergence of a tetragonal InTe phase at high indium contents. A likely answer to this lies again with the strong In segregation, in the sense that we have produced not a large, uniform single crystal with a high indium content but only an In enriched surface layer. It seems reasonable to expect that the phase diagram could be quite different for very thin films.

IV. ELECTRONIC STRUCTURE MEASUREMENTS

In Figure 2 we show normal emission photoemission intensity maps as a function of photon energy for the $x = 0.41$ film. The band structure is in good agreement with the $\Gamma$-$L$-$\Gamma$ direction of bulk SnTe, providing further confidence that we are studying well defined, (111) oriented (Sn,In)Te as opposed to In$_2$Te$_3$ clusters. At normal emission the bulk L points are probed at photon energies of approximately 17 eV, 55 eV and 113 eV, and around these energies the bulk valence band crosses the Fermi level at $\bar{\Gamma}$. Upon closer inspection (Figure 3) it becomes apparent that two distinct pairs of bands are present. The innermost pair broadens and disperses to a higher binding energy as the photon energy is increased, consistent with the bulk valence band. In contrast, the outermost pair does not disperse, a characteristic property of surface states. As is also the case for the surface states of (Pb,Sn)Se(111), the surface state intensity is resonantly enhanced at photon energies which probe the bulk L point.

The dispersion of the surface state resembles the linear dispersion typical of topological surface states close to a Dirac point, and indeed one might anticipate topological states on the basis of previous studies of SnTe and Sn$_{0.955}$In$_{0.045}$Te$_{14}$. In Figure 4 we quantify the dispersion, tracking peak positions by fitting individual momentum distribution curves taken along $\bar{K}$-$\bar{\Gamma}$-$\bar{K}$ with four Lorentzian peaks. Linear extrapolation of the surface state bands then provides an estimate of the binding energy of the (assumed) Dirac points: 375 meV above the Fermi level for the $x = 0.41$ film and 312 meV for the $x = 0.23$ film. Previous studies found values of 50 meV for both SnTe and Sn$_{0.955}$In$_{0.045}$Te$_{14}$, at least partially due to surface band-bending. The larger value we observe compared to these studies may reflect different surface band-bending, but is also consistent with a significantly higher indium content.

Constant energy surface mapping of the $\Gamma$ surface state (Figure 5) reveals both intensity modulations and corresponding second derivative images after box smoothing along the energy direction. The outermost bands do not disperse with increasing photon energy, identifying them as a surface state. The innermost pair broadens and moves to higher binding energy, consistent with the bulk valence band at bulk L.

FIG. 2. (a) Room temperature, normal emission photoemission spectra for the $x = 0.41$ sample as a function of photon energy. Such a measurement maps the $k_z$ dispersion along the bulk L-$\Gamma$-$L$ high symmetry direction. The experimental dispersions agree well with tight binding calculations for bulk SnTe (b, adapted with permission from Littlewood et al). (c) A schematic depiction of the relationship between the (111) surface and the bulk Brillouin zone illustrates the projection of Fermi ellipsoids at the bulk L points onto $\bar{\Gamma}$ and $\bar{M}$ in the surface Brillouin zone.

FIG. 3. Photon energy dependent ARPES of the hole pockets at $\bar{\Gamma}$ for the $x = 0.41$ sample ($T \approx 230$ K). Raw spectra (a) and corresponding second derivative images after box smoothing along the energy direction (b). The outermost bands do not disperse, consistent with the bulk valence band at bulk L.
The table shows binding energy values for different samples.

**Table:**

<table>
<thead>
<tr>
<th>Sample</th>
<th>Binding Energy (eV)</th>
</tr>
</thead>
<tbody>
<tr>
<td>Sample A</td>
<td>0.2, 0.0, -0.2</td>
</tr>
<tr>
<td>Sample B</td>
<td>0.1, 0.1, 0.0</td>
</tr>
</tbody>
</table>

**Figure 4:** Quantitative dispersion mapping of the Γ hole pockets for two different indium content samples (a,b). By fitting individual momentum distribution curves, the dispersion of both the bulk and surface bands can be tracked.

**Figure 5:** Room temperature three-dimensional ARPES mapping of the Γ hole pockets in the $x = 0.23$ film at $h\nu=18$ eV. Above the Fermi level the contours resemble an isotropic 2-dimensional hole gas, but at higher binding energies the surface state becomes severely warped towards $\bar{M}$. This becomes particularly clear in second derivative images (b,c).

**Figure 6:** Fermi surface maps covering several surface Brillouin zones of the $x = 0.41$ (a) and $x = 0.23$ (c) samples. The intensity of different features within the maps is highly non-uniform, but cuts along $\bar{M} - \Gamma - \bar{M} - K$ in both samples (b,c) indicate anisotropic hole pockets located at $\bar{M}$.

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**Text:**

 tolerate possible, with significant consequences for the surface density wave instabilities, lifetime anisotropy and an out-of-plane spin texture. Previous studies of (111) oriented SnTe and (Sn,In)Te did not sufficiently resolve the Fermi surface, whilst in (111) oriented Pb$_{1-x}$Sn$_x$Se the warping effect is expected to be much less severe owing to the weaker spin-orbit coupling of selenium compared to tellurium (analogous to the comparison of Bi$_2$Se$_3$ and Bi$_2$Te$_3$). The combination of warping effects with a superconducting transition makes Sn$_{1-x}$In$_x$Te(111) an interesting system for continued studies.

Based on consideration of mirror symmetry and where the bulk $L$-points project to, Dirac points are also predicted to exist at $\bar{M}$ (Fig. 2c). However the configuration of these Dirac points depends on the surface termination.

In contrast to the well studied (100) natural cleavage plane, the (111) face of SnTe is strongly polar. Different surface terminations and reconstructions are therefore possible, with significant consequences for the surface electronic structure. Thermodynamic calculations for SnTe indicate that a $(1 \times 1)$-Te termination is the most stable, in which case the $\bar{M}$ Dirac point is expected to lie close to the bulk conduction band edge. Combined with the strong p-type doping, it is therefore not obvious that Dirac cones should be experimentally observable at $\bar{M}$. This is further complicated by the strong
intensity resonances in this system - even if present, surface states can only be resolved at particular photon energies. In Figure 6a,c we show wide-area Fermi surface maps for both the $x = 0.41$ sample ($\nu = 64$ eV) and the $x = 0.23$ sample ($\nu = 94$ eV). In both cases there are weakly resolved anisotropic hole pockets at $M$. In Figure 6b,d we extract energy-momentum spectra from regions where these pockets are most visible. The fact that the linear dispersions appear to be unchanged between the 64 eV and 94 eV scans is suggestive that these are indeed the lower portions of $M$ surface state Dirac cones.

V. CONCLUSIONS

By growing (Sn,In)Te films in-situ, we have bypassed the need for cleavable bulk crystals and been able to study the high-indium regime of this material. Importantly, we can confirm that surface states similar in character to the topological states on SnTe continue to exist at very high indium contents. While spin-resolved measurements are always a necessary requirement to confirm the nature of these surface states, our observation is nonetheless highly encouraging for the continuing efforts towards superconducting topological insulators. In particular, we note that the increase in critical temperature for Sn$_{1-x}$In$_x$Te when the indium content reaches $x = 0.45$ brings it within a highly accessible liquid helium experimental regime. However as our measurements confirm, it remains an important and unsolved material challenge to realize n-type doping of (Sn,In)Te such that transport properties are not dictated by trivial bulk bands. To this end, the possibility of high quality thin-film growth demonstrated here may open up new research directions.

ACKNOWLEDGMENTS

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Area quantification was performed by fitting with a spin-orbit split Voigt doublet and Shirley background. The cross sections used were In4d$_{70}$eV = 16.1 Mb, In4d$_{94}$eV = 2.17 Mb, Sn4d$_{70}$eV = 23.9 Mb and Sn4d$_{94}$eV = 3.26 Mb, obtained from Elettra’s “WebCrossSections” service.

See supplemental material

Cross sections used were In4d$_{2.14}$eV = 57.8 kb, In4d$_{4.14}$eV = 8.00 kb, Sn4d$_{2.14}$eV = 68.9 kb and Sn4d$_{4.14}$eV = 9.75 kb, obtained from M. B. Trzhaskovskaya, V. I. Nefedov and V. G. Yarzhemsky, Photoelectron angular distribution parameters for elements Z=1 to Z=54 in the photoelectron energy range 100-5000eV, At. Data Nucl. Data Tables 77, 97 (2001)


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